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JMD 6/13/07

RESPONSE UNDER 37 C.F.R. § 1.116
EXPEDITED PROCEDURE
GROUP 2812
PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q80822

Masatomo SHIBATA

Appln. No.: 10/813,176

Group Art Unit: 2813

Confirmation No.: 4446

Examiner: DOLAN, JENNIFER M.

Filed: March 31, 2004

For: III-V NITRIDE SEMICONDUCTOR SUBSTRATE AND ITS PRODUCTION METHOD

RESPONSE TO ACTION OF MARCH 2, 2007

MAIL STOP AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Please consider the following Applicant's response to the outstanding rejection of March 2, 2007. The claims are not amended.

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